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#### **XP601: Outline**



• 2 versions of lithium evaporator (LITER-1) installed in succession on upper port aimed 22° downward toward of lower CS and divertor graphite tiles.

• LITER-1 temperatures (450–680°C) produced evaporation rates of 0.08 to 35 mg/min with a Gaussian-like angular distribution with a 1/e full width of about 22°.

• 12 separate depositions (1.6 mg to 4.8 g) of lithium were performed (9 g total). Lower Single-Null L-mode and H-mode, and Double-Null Reversed-Shear plasmas were studied.

• After lithium coating, reference ratio of oxygen to carbon emission lower than achieved with boronization.

Other effects observed under some conditions:

5-29% decreases in  $n_e$  and increases up to 15% in  $T_e$ , 20% in  $T_i$ , 20% in n/sec, reductions in H-mode ELM frequency, increased long pulse fueling, improved reverse shear....



## **Experimental Sequence**



Evaporation Number	mg	Evaporation Duration	Time to 1st Shot	He Discharge Conditioning	Туре	Ref Shot	Compare Shot	Comments
E-1, 4/07/06	1.6	11 min		none	L	none		no change
E-2, 4/11/06	14.3	245 min	151 min	7 He, 4/10/0	L	119872	119854	no change
E-3, 4/11/06	77.0	128 min	11 min	none	L	119875	119854	no change
E-4, 4/12/06	215	128 min	167 min	none	L	119879	117087	no change
E-5, 4/12/06	0					none		
E-6, 4/13/06	643	369 min	85 min	none	L	119894	119887	no change
E-7, 5/04/06	378	63 min	23 min	6 He, 5/04/06	L	120474	120464	first noteworthy changes
E-8, 5/05/06	0					none		
E-9, 6/09/06	<b>440</b> <sup>c)</sup>	<b>76 min</b>	75 min	none	Н	121323	121270	similar changes
E-10, 6/09/06	203 <sup>a)</sup>	50 min	17 min	none	Н	121334	121270	no change
E-11, 6/09/06	295 <sup>b)</sup>	36 min	25 min	none	Н	121336	121270	marginal increase
E-12, 6/22/06	4780	12.3 hrs	160 min	none	Н	121507	121504	similar changes
E-13, 6/22/06	1046	66 min	24 min	none	Н	121512	121504	similar changes
E-14, 6/22/06	1008	28 min	8 min	none	Н	121521	121504	similar changes



# Lithium Reduced Da Luminosity, Loop Voltage and Flux Consumption



•  $\mathbf{D}\alpha$  reduced after Li



•121521 after an additional 1.1g Li between discharges (2nd evaporation after 4.8g)



#### Lithium on PFCs May Be Broadening Profiles



from \EFIT02, Shot 121504, time=from \EFIT02, Shot 121507, time=401ms)2, Shot 121512, from \EFIT02, Shot 121521, time=403ms



# LSN L-mode Exhibited Changes After 0.38g Lithium PFC Coating





# H-mode Exhibited Changes After 0.44g Lithium Coating without pre Helium Discharge Conditioning





HWK NSTX RR06

## Summary and Conclusions



• Effect on density for XP601 persists for one shot after application of lithium

Other plasma effects persist longer

• For present geometry, performance improvements appear not dependent on quantity of lithium deposited beyond certain threshold

- Thereafter small depositions between shots appear to recover conditions
- Indications of possible long-term improvements
- The initial results suggest upgrade of present capability for
  - Faster between-shot evaporation
  - Broader coverage on lower divertor target region

